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			APPLICANT Masao SHINDO				
(PTO-1449)			FILING DATE February 20, 2004	GROUP			
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	CITE NO.	Document Number Number-Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear		
<i>M</i>	US	5,856,003	01/05/1999	Chiu			
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EXAMINER'S INITIALS	CITE NO.	Foreign Patent Document Country Codes - Number & Kind Codes (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Relevant Figures Appear	Translation	
						Yes	No
<i>M</i>		JP 59-50227	12/07/1984	TOSHIBA CORP		(Japan w/English Abstract)	
<i>M</i>		JP P2001-291781A	10/19/2001	MATSUSHITA ELECTRIC IND CO LTD		(Japan w/English Abstract)	
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
EXAMINER'S INITIALS	CITE NO.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.					
<i>M</i>		Don H. LEE, et al., "Ion-Implanted Semiconductor Devices", Proceedings of the IEEE, pp.1241-1255, September 1974					
EXAMINER <i>H. Lee TSM</i>				DATE CONSIDERED <i>7/22/04</i>			

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